CLAIMS

1. A curable surface modifier comprising a curable fluorine-containing resin (I) which is soluble in general purpose solvents and comprises a fluorine-containing ethylenic polymer (IAB) having a moiety A and a moiety B in at least a part of the same side chain or different side chains thereof orcomprises fluorine-containing ethylenic polymer (IA) having a moiety A in at least a part of its side chain and a fluorine-containing ethylenic polymer (IB) having a moiety B in at least a part of its side chain, in which the moiety A has, at its end, one or two or more polyfluoropolyether chains P represented by the formula (1):

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Rf-O-(
$$CX^{1}_{2}CF_{2}CF_{2}O$$
)_{n1} ($CFCF_{2}O$)_{n2} ($CF_{2}CF_{2}O$)_{n3} ($CF_{2}O$)_{n4} | CF_{3}

wherein n1, n2, n3 and n4 are the same or different and each is 0 or an integer of 1 or more and n1 + n2 + n3 + n4 is an integer of 7 to 40; X^1 are the same or different and each is H, F or Cl; Rf is a fluorine-containing alkyl group having 1 to 10 carbon atoms,

the moiety B has one or two or more self-crosslinkable functional groups Y at its end, and

an ethylenic polymer moiety M remaining by excluding the moiety A and the moiety B from the fluorine-containing ethylenic polymer constituting the resin (I) does not contain fluorine atom or is an ethylenic polymer moiety in which a part of hydrogen atoms thereof are replaced by fluorine atoms up to a fluorine content of not more than

10 % by weight.

- 2. The curable surface modifier of Claim 1, wherein the fluorine content of curable fluorine-containing resin (I) which is soluble in general purpose solvents is not less than 0.1 % by weight and not more than 35 % by weight.
- 3. The curable surface modifier of Claim 1 or 2, wherein the ethylenic polymer moiety M contains a structural unit of the formula 10 (2):

or the formula (3):

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wherein X^2 is H or a bond; X^3 is H, F or CH₃.

4. The curable surface modifier of any of Claims 1 to 3, wherein the self-crosslinkable functional group Y of the moiety B is at least one selected from the group consisting of

wherein X⁴ is H, CH₃ or F; X⁵ is H or CH₃.

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- 5. A method of modifying a surface of a substrate which comprises applying the curable surface modifier of any of Claims 1 to 4 on the substrate and curing.
- 6. The surface modifying method of Claim 5, wherein the substrate is one having an antireflection film on its surface.
- 7. A surface-modified antireflection film of multi-layer structure which comprises an antireflection film and a continuous or discontinuous cured film of the curable surface modifier of any of Claims 1 to 4 which is formed directly on the antireflection film.
 - 8. A curable composition for surface modification which is crosslinkable with active energy rays and comprises:
 - (a) a curable fluorine-containing resin (I) which is soluble in general purpose solvents and comprises a fluorine-containing ethylenic polymer (IAB) having a moiety A and moiety B in at least a part of the same side chain or different side chains thereof or comprises a fluorine-containing ethylenic polymer (IA) having a moiety A in at least a part of its side chain and a fluorine-containing ethylenic polymer (IB) having a moiety B in at least a part of its side chain, in which the moiety A has, at its end, one or two or more polyfluoropolyether chains P represented by the formula (1):

Rf-O-(
$$CX^{1}_{2}CF_{2}CF_{2}O$$
)_{n1} ($CFCF_{2}O$)_{n2} ($CF_{2}CF_{2}O$)_{n3} ($CF_{2}O$)_{n4} | CF_{3}

wherein n1, n2, n3 and n4 are the same or different and each is 0 or an integer of 1 or more and n1 + n2 + n3 + n4 is an integer of 7 to 40; X¹ are the same or different and each is H, F or Cl; Rf is a fluorine-containing alkyl group having 1 to 10 carbon atoms, the moiety B has one or two or more self-crosslinkable functional groups Y at its end, and

- an ethylenic polymer moiety M remaining by excluding the moiety A and the moiety B from the fluorine-containing ethylenic polymer constituting the resin (I) does not contain fluorine atom or is an ethylenic polymer moiety in which a part of hydrogen atoms thereof are replaced by fluorine atoms up to a fluorine content of not more than 10 % by weight, and
 - (b) an active energy curing initiator.

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- 9. A curable composition for surface modification which is crosslinkable with active energy rays and comprises:
- 20 (a) a curable fluorine-containing resin (I) which is soluble in general purpose solvents and comprises a fluorine-containing ethylenic polymer (IAB) having a moiety A and moiety B in at least a part of the same side chain or different side chains thereof or comprises a fluorine-containing ethylenic polymer (IA) having a moiety A in at least a part of its side chain and a fluorine-containing ethylenic polymer (IB) having a moiety B in at least a part of its side chain, in which the moiety A has, at its end, one or two or more polyfluoropolyether chains

P represented by the formula (1):

Rf-O-(
$$CX^{1}_{2}CF_{2}CF_{2}O$$
)_{n1} ($CFCF_{2}O$)_{n2} ($CF_{2}CF_{2}O$)_{n3} ($CF_{2}O$)_{n4} ($CF_{3}O$

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wherein n1, n2, n3 and n4 are the same or different and each is 0 or an integer of 1 or more and n1 + n2 + n3 + n4 is an integer of 7 to 40; X^1 are the same or different and each is H, F or Cl; Rf is a fluorine-containing alkyl group having 1 to 10 carbon atoms,

the moiety B has one or two or more self-crosslinkable functional groups Y at its end, and

an ethylenic polymer moiety M remaining by excluding the moiety A and the moiety B from the fluorine-containing ethylenic polymer constituting the resin (I) does not contain fluorine atom or is an ethylenic polymer moiety in which a part of hydrogen atoms thereof are replaced by fluorine atoms up to a fluorine content of not more than 10 % by weight,

- (b) an active energy curing initiator, and
- (c) at least one general purpose solvent selected from the group consisting of ketone solvents, acetic acid ester solvents and alcohol solvents or a solvent mixture containing the general purpose solvent.
 - 10. An antireflection film obtained by applying, on a substrate, a composition for forming an antireflection film which comprises:
 - (d) a fluorine-containing resin (II) which is soluble in general purpose solvents, has a fluorine content of not less than 1 % by weight and not

more than 35 % by weight and comprises a fluorine-containing ethylenic polymer (IAB) having a moiety A and moiety B in at least a part of the same side chain or different side chains thereof or a fluorine-containing ethylenic polymer (IA) having a moiety A in at least a part of its side chain, in which the moiety A has, at its end, one or two or more polyfluoropolyether chains P represented by the formula (1):

Rf-O
$$\dagger$$
 CX¹₂CF₂CF₂O \dagger _{n1} \dagger CFCF₂O \dagger _{n2} \dagger CF₂CF₂O \dagger _{n3} \dagger CF₂O \dagger _{n4} CF₃

wherein n1, n2, n3 and n4 are the same or different and each is 0 or an integer of 1 or more and n1 + n2 + n3 + n4 is an integer of 7 to 40; X^1 are the same or different and each is H, F or Cl; Rf is a fluorine-containing alkyl group having 1 to 10 carbon atoms, an ethylenic polymer moiety MA remaining by excluding the moiety A and the moiety B from the fluorine-containing ethylenic polymer constituting the resin (II) does not contain fluorine atom or is an ethylenic polymer moiety in which a part of hydrogen atoms thereof are replaced by fluorine atoms up to a fluorine content of not more than 10 % by weight, and

(e) a material for antireflection film.

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11. A curable resin composition comprising:

(1) a curable fluorine-containing resin (III) containing up to 100 % by mole of a fluorine-containing polymer (IIINC) which has a number average molecular weight of 500 to 1,000,000 and is represented by

the formula (4):

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$$-(N)-(C)-$$
 (4)

wherein the structural unit N is a structural unit derived from a fluorine-containing ethylenic monomer and represented by the formula (N):

$$+CX^{15}X^{16}-CX^{17}+$$
 (N) (CX¹⁸X¹⁹)a(C=O)b(O)c-Rf¹

in which X¹⁵ and X¹⁶ are the same or different and each is H or F; X¹⁷ is H, F, CH₃ or CF₃; X¹⁸ and X¹⁹ are the same or different and each is H, F or CF₃; Rf¹ is an organic group in which 1 to 3 Y¹ or Y² (Y¹ is a monovalent organic group having 2 to 10 carbon atoms and an ethylenic carbon-carbon double bond at its end and Y² is a monovalent organic group having 2 to 100 carbon atoms and 1 to 5 crosslinkable cyclic ether structures, in which hydrogen atoms may be replaced by fluorine atoms) are bonded to a fluorine-containing alkyl group having 1 to 40 carbon atoms or a fluorine-containing alkyl group having 2 to 100 carbon atoms and ether bond; a is 0 or an integer of from 1 to 3; b and c are the same or different and each is 0 or 1,

the structural unit C is a structural unit derived from a monomer copolymerizable with the fluorine-containing ethylenic monomer providing the structural unit N, and

the structural units N and C are contained in amounts of from 0.1 to 100 % by mole and from 0 to 99.9 % by mole, respectively, and

(2) a fluorine-containing resin (II) which is soluble in general purpose solvents, has a fluorine content of not less than 1 % by weight and not more than 35 % by weight and comprises a fluorine-containing ethylenic polymer (IAB) having a moiety A and moiety B in at least a part of the same side chain or different side chains thereof or a fluorine-containing ethylenic polymer (IA) having a moiety A in at least a part of its side chain, in which the moiety A has, at its end, one or two or more polyfluoropolyether chains P represented by the formula (1):

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Rf-O-(
$$CX^{1}_{2}CF_{2}CF_{2}O$$
)_{n1} ($CFCF_{2}O$)_{n2} ($CF_{2}CF_{2}O$)_{n3} ($CF_{2}O$)_{n4} | CF_{3}

wherein n1, n2, n3 and n4 are the same or different and each is 0 or an integer of 1 or more and n1 + n2 + n3 + n4 is an integer of 7 to 40; X^1 are the same or different and each is H, F or Cl; Rf is a fluorine-containing alkyl group having 1 to 10 carbon atoms, an ethylenic polymer moiety MA remaining by excluding the moiety A and the moiety B from the fluorine-containing ethylenic polymer constituting the resin (II) does not contain fluorine atom or is an ethylenic polymer moiety in which a part of hydrogen atoms thereof are replaced by fluorine atoms up to a fluorine content of not more than 10 % by weight.

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- 12. A method of forming a cured article which comprises; coating a liquid composition comprising:
- (i) the material (e) for antireflection film of Claim 10 or the curable

fluorine-containing resin (III) of Claim 11,

- (ii) the fluorine-containing resin (II) of Claim 10, and
- (iii) a solvent;

drying to form a coating film; and

- 5 curing the coating film.
 - 13. The method of Claim 12, wherein the cured article is an antireflection film.